

# ACTIVATION ENERGY OF $^3\text{He}$ ADSORBED ON GRAFOIL AT REGISTRY

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## ABSTRACT

The pulsed Nuclear Magnetic Resonance (NMR) has been employed to study the properties of  $^3\text{He}$  adsorbed on grafoil. The work was done at 2.6 and 5.1 MHz, while the substrate orientation was 90 deg. The spin-lattice relaxation time  $T_1$  and the spin-spin relaxation time  $T_2$  were measured as a function of coverage at temperature of 1.2 K. The activation temperature was determined from  $T_1$  and  $T_2$  temperature dependence for a number of coverage at the perfect registry. At this phase; the Helium atoms are regularly distributed on the grafoil mesh was recorded. The activation temperature was found to have its maximum value at perfect registry which indicates the slowing down of the motion.

## INTRODUCTION

During the last two decades [1-4], great interest has been given to the Physics of low dimensional system.  $^3\text{He}$  adsorbed on grafoil [5] is one of the most attractive two dimensional systems, especially in submonolayer films where a variety of Phases have been found by specific heat measurements [1,3]. These phases are mainly the two dimensional solid, the registered lattice gas and the two dimensional fluid. A series of strong heat capacity peaks was observed around 3 K. These peaks were interpreted [1] as a second order phase transition from disordered two dimensional gas phase to an ordered lattice gas in registry with grafoil structure. The

registered phase is  $\sqrt{3} \times \sqrt{3}$  epitaxial system where the  $^3\text{He}$  atoms are in registry with the substrate structure. In such a case, every helium atom occupies one out of each three sites of grafoil hexagon to form a triangular lattice structure with spacing  $4.2\text{\AA}$ . This has been detected by neutron scattering experiments [6]. Thus the substrate plays an important role in the spins motion. Also one of the frequency dependence relaxation mechanisms is due to the motion in the grafoil local fields.

The aim of the present study is to investigate the coverage and the temperature dependence of both relaxation times in the neighborhood of the perfect registry.

## EXPERIMENTAL

Measurements of the spin-lattice relaxation time  $T_1$  and the spin-spin relaxation time  $T_2$  were carried out using the pulse NMR technique. A home made broad band

spectrometer, as explained by Cowan et al in reference [7], was used to cover a wide range of measurements between 1 and 10 MHz. The master oscillator used is 5600 Rockland synthesizer with excellent stability and low noise. The minimum frequency which could be achieved is 0.1 MHz and the maximum one is 160 MHz. Two Larmor frequencies were chosen to perform the work; 2.6 and 5.1 MHz. The measurements were classified into two sets:

- a-  $T_1$  and  $T_2$  were determined as a function of coverage  $x$  at constant temperature  $T=1.2\text{ K}$ , where the spins exhibit quantum motion and the relaxation times are independent of temperature.
- b- The relaxation times  $T_1$  and  $T_2$  were measured as a function of temperature in a range extends between 1 and 4.2 K. These data were taken at fraction of monolayer between  $x=0.57$  and  $x=0.625$  in steps of 0.005 monolayer.

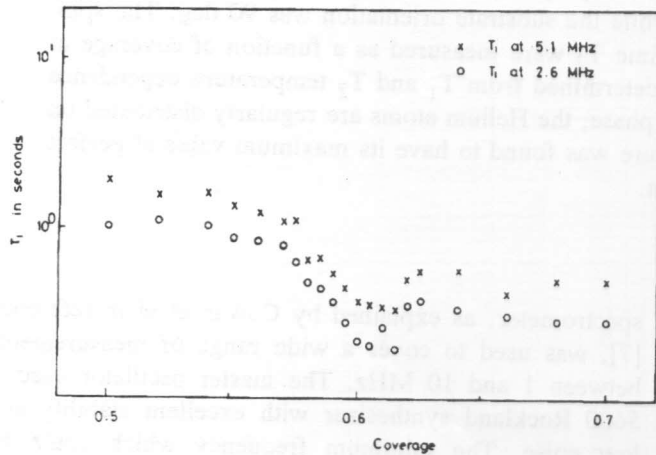
In these measurements the angle of orientation between the external magnetic field and the normal to the substrate was taken to be  $\pi/2$ . The saturation recovery method was used to perform the data for  $T_1$ . While the spin echo technique was applied for measurements of  $T_2$  [8].

## RESULTS AND DISCUSSIONS

The change of the spin-lattice relaxation time as a function of coverage at temperature of 1.2 K and two Larmor frequencies 2.6 and 5.1 MHz is illustrated in Figure (1). It is noticed that at low coverage  $T_1$  decreases slowly with the increase of  $x$ . Above  $x=0.57$  monolayer

the decrease of  $T_1$  becomes steeper to have its minimum value at perfect registry,  $x \leq 0.61$  of monolayer.

An increase of  $T_1$  is observed for  $x > 0.61$  which becomes almost coverage independent for higher values of  $x$ . The behavior is similar at the two Larmor frequencies although the data shows that the position and the depth of the dip is slightly frequency dependence.

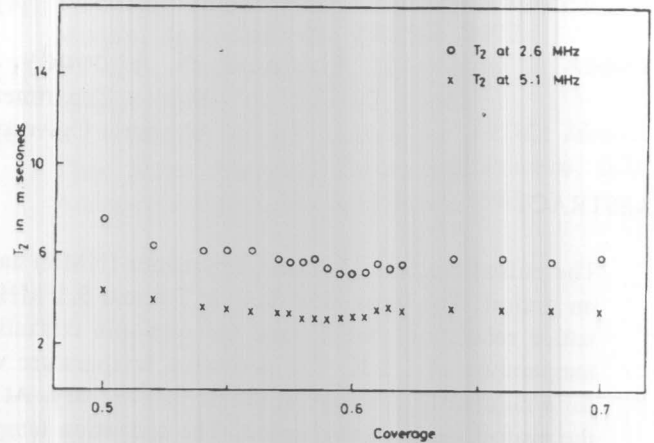


**Figure 1.** The variation of  $T_1$  as a function of coverage at  $T = 1.2$  K.

On the other hand, a display of the variation of the spin-spin relaxation time with coverage is shown in Figure (2) under the same conditions of temperature and frequency as mentioned above. A similar behavior as that of  $T_1$  is repeated with the exception that instead of the sharp minimum; there is only a shallow one at perfect registry.

It has to be mentioned that  $T_1$  drawn in units of seconds while  $T_2$  is in m.seconds. The existence of the minima in both  $T_1$  and  $T_2$  around perfect registry is attributed to the slowing down of the spins motion at registry. The shallow minima observed in  $T_2$  compared to  $T_1$  is interpreted as due to the contribution of the grafoil local fields towards the motion of the spins. A similar behavior was reported by Owers-Bradly et al [9] and Richards et al [10] at frequency of 1 MHz.

To estimate a value for the activation temperature (activation energy), the set (b) of data was performed.  $T_1$  and  $T_2$  were measured as a function of inverse temperature for Larmor frequencies of 2.6 and 5.1 MHz. These measurements were taken at a number of coverage from below the perfect registry;  $x=0.59$ ; to above of it;  $x=0.62$ ; in steps of 0.005 monolayer. Figures (3) and (4) demonstrate the temperature dependence of  $T_1$  and  $T_2$  at the most probable perfect registry coverage; namely  $x=0.6$  and  $x=0.61$  monolayer.



**Figure 2.** The variation of  $T_2$  as a function of coverage at  $T = 1.2$  K.

It is convenient to classify the data into three regions. Region I, above 3 K, there is only a slight change in both  $T_1$  and  $T_2$  with decreasing of the temperature. Region II, from 2-3 K, both relaxation times are decreasing exponentially with lowering the temperature. The decrease in  $T_1$  is faster than that of  $T_2$ . Region III below 2 K, where the values of  $T_1$  and  $T_2$  are independent of temperature.

We assume that the activation energy of the atom is given by  $E_a$  [11], then:

$$E_a = E_f + E_m$$

where  $E_f$  is the formation energy of vacancies and  $E_m$  is the migration energy necessary to overcome the potential barrier due to repulsion between the Helium atoms.

In solid Helium, motion is thought to be quantum tunneling [11], then  $E_m = 0$ . If we assume the same behavior is true for two dimensions [12], then  $E_a$  will be given by  $E_f$  only. A direct result of vacancies is the modulation of the internuclear magnetic dipolar interactions [12]. Therefore, the mobility of vacancies implies the mobility of adatoms. At registry, the density of vacancies were found by Sato and Sugawara [12] to be 4.2 %.

However, the activation temperature of vacancies or adatoms was evaluated from the second region of Figures (3) and (4) where the data were found to obey the Arrhenius relation;

$$T_{1,2} = T_0 \exp(-E_a/kT)$$

where  $T_0$  is a constant which could be evaluated from the graphs and  $k$  is Boltzman constant while  $E_a/k$  is the activation temperature.

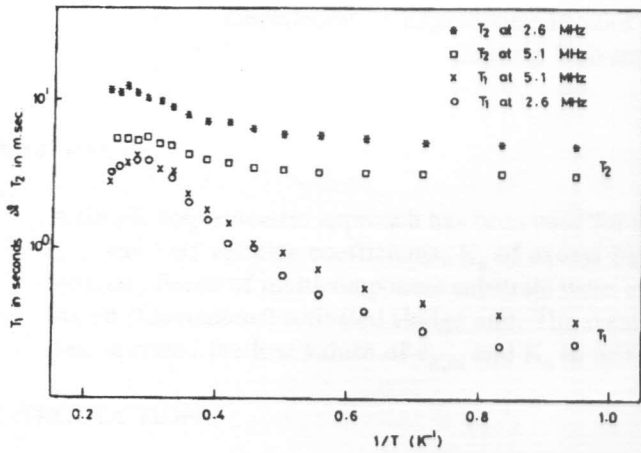


Figure 3. Temperature dependence of  $T_1$  and  $T_2$  at  $x=0.6$  monolayer.

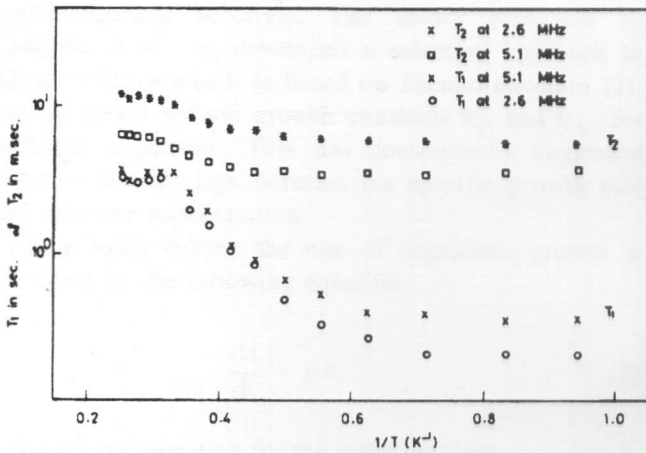


Figure 4. Temperature dependence of  $T_1$  and  $T_2$  at  $x=0.61$ .

The activation temperature is performed as a function of coverage in Figure (5). The activation temperature has a maximum around perfect registry whether it is obtained from  $T_1$  or  $T_2$  data at both frequencies. The  $E_a/k$  obtained from  $T_1$  shows a maximum value of 8.8 while that obtained from  $T_2$  has a lower value of 4.8. This difference is attributed to the effect of the substrate local fields on  $T_2$ . The same discrepancy was claimed by Owers-Bradly [9] and Richards [10] for Larmor frequency of 1 MHz. On the other hand, Sato and Sugawara [12] did not see any change of  $E_a/k$  with

increase of coverage for Larmor frequency of 10 MHz. This seems to be due to different treatment of the substrate and hence different surface nature which might affect the mobility of the Helium atoms.

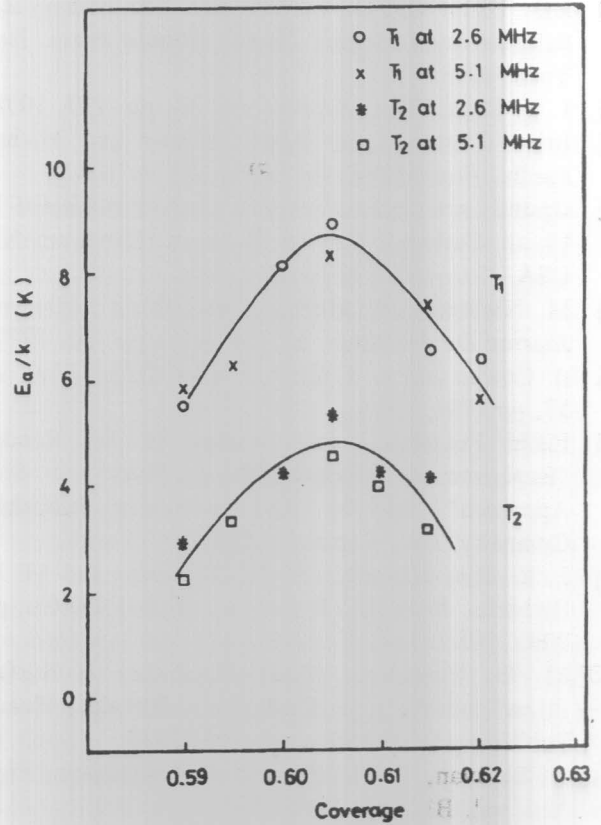


Figure 5. The change of the activation temperature with coverage as obtained from  $T_1$  and  $T_2$  temperature dependence.

As it can be seen from Figure (5), the perfect registry is most probable to be around  $x=0.605$ . Therefore one may suggest that a more reliable identification of the perfect registry can be obtained from the variation of activation temperature with coverage.

From the above analysis we may conclude that around perfect registry the motion of the spins slows down and has its lowest value at perfect registry. This motion is affected to some extent by the substrate local fields.

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